Electrically controlled two-dimensional electron-hole fluids

Yongxin Zeng and A. H. MacDonald

Department of Physics, University of Texas at Austin, Austin, Texas 78712, USA

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We study the electronic properties of dual-gated electron-hole bilayers in which the two layers are separated by a perfectly opaque tunnel barrier. Combining an electrostatic and thermodynamic analysis with mean-field theory estimates of interacting system chemical potentials, we explain the dependence of the electron and hole densities on the two gate voltages. Because chemical potential jumps occur for both electrons and holes at neutrality, there is a finite area in gate voltage parameter space over which electron and hole densities are equal. In that regime the electron-hole pair density depends only on the sum of the two gate voltages. We are able to explain a recent experimental study of electrically controlled bilayers by allowing for interlayer tunneling and using a nonequilibrium steady-state transport picture.

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I. INTRODUCTION

Recent progress [1–14] in fabricating and processing twodimensional (2D) semiconductor multilayers has opened up new opportunities to realize and study the properties of 2D electron-hole systems. Provided that the tunneling between layers is negligible, a bias voltage applied to a bilayer with a spatially indirect band gap, like the one in Fig. 1, simply adjusts the effective band gap. Above a threshold bias voltage the effective band gap is reduced to zero so that electrons are induced in the conduction band of one 2D semiconductor layer, and holes in the valence band of the adjacent layer. In the limit of low electron and hole densities, a regime of bias and gate voltages exists in which the electrons and holes pair into excitonic bound states, and separate electrical contacts can then be used to adjust the exciton chemical potential [15]. In the general case, however, the electron and hole densities are unequal, allowing unprecedented access to systems of fermions with attractive mutual interactions, whose densities are unbalanced [16–19]. In this article we outline a rigorous framework that relates the dependence of electron and hole densities in the semiconductor bilayers on bias and gate voltages to thermodynamic properties of the interacting electron-hole fluid, focusing first on the case of perfectly opaque barriers between the active layers and then discussing transport and electronic properties in the case where charge leakage between layers plays an important role.

Our paper is organized as follows. Section II presents a formal analysis of the perfect barrier limit in terms of relevant thermodynamic properties of the interacting electronhole fluid. In Sec. III we use a mean-field theory of the electron-hole fluid to obtain some concrete but approximate results which illustrate important key qualitative features, in particular the consequences of the singularities that electronhole pairing produces in thermodynamic properties. In Sec. IV we combine the results from the previous two sections and show how the carrier densities in the two layers are controlled by the gate voltages. We find that there is a finite area region in the gate-control parameter space where the electron and hole densities are exactly equal, which is especially interesting for the study of exciton physics. Section V generalizes the analysis to the case of nonzero leakage currents and provides an explanation for the transport characteristics observed in a recent experiment [1]. Finally, in Sec. VI we conclude with a discussion of the prospects for realizing new physics in these systems.

II. DUAL GATED ELECTRON-HOLE FLUIDS

We assume a dual gated structure like that illustrated in Fig. 1. For definiteness we will focus on the case in which the two gates are physically identical and held at the same voltage. We choose the Fermi energy of the gates as the zero of energy, and also set the zero of the electric potential at the gate planes. We assume that the voltages on the contacts to the electron and hole layers, $-V_e$ and $+V_h$, can be varied at will, and that no current can flow between layers. Under that circumstance the contacts on the two layers act like reservoirs whose voltages fix the electrochemial potentials of the electrons in those layers. We also assume that $V_e > 0$ and $V_h > 0$ so that the large voltages populate the conduction band in the electron layer and the valence band in the hole layer, allowing us to disregard the remote band degrees of freedom in both layers.

Starting from neutrality and increasing V_e , the electron layer begins to charge when V_e reaches the threshold voltage at which its electrochemical potential reaches the bottom of the conduction band E_c , whereas the hole layer begins to charge when its electrochemical potential reaches the top of the valence band E_v . We focus on the regime in which both layers are charged, which we refer to as the *p*-*n* regime. Applying the Poisson equation we obtain the following relationship between the electric potentials $-\phi_e$ and $+\phi_h$ and the free

$$\frac{4\pi ne^2}{\epsilon} = \frac{\phi_e}{d_e} + \frac{\phi_e + \phi_h}{d_s},$$

$$\frac{4\pi pe^2}{\epsilon} = \frac{\phi_h}{d_h} + \frac{\phi_e + \phi_h}{d_s},$$
(1)

where d_e and d_h are the distances from top and bottom gates to the electron and hole layers, and d_s is the spacing between electron and hole layers. Note that we have absorbed a factor of electron charge e in the definition of $\phi_{e/h}$ and $V_{e/h}$ so that they have units of energy. The inverse of this linear relationship is

$$\phi_e(n, p) = \frac{4\pi e^2 d_e}{\epsilon} \frac{(d_h + d_s)n - d_h p}{d_e + d_h + d_s},$$

$$\phi_h(n, p) = \frac{4\pi e^2 d_h}{\epsilon} \frac{(d_e + d_s)p - d_e n}{d_e + d_h + d_s}.$$
(2)

Assuming that d_e , $d_h \gg d_s$, as is typical in experiment [1], we see that *n* and *p* will typically be nearly equal in magnitude, i.e., that this gating geometry favors nearly balanced electronhole fluids but allows for large values of the individual layer densities:

$$n \approx p \approx \frac{\epsilon}{4\pi e^2} \frac{\phi_e + \phi_h}{d_s}.$$
 (3)

Due to the small interlayer distance, the electric field between the two layers is typically much larger than the electric field between the active layers and the gates.

The dependence of the carrier densities on the bias voltages applied to the active layers is determined by the following pair of nonlinear equations:

$$\phi_{e}(n, p) + \mu_{e}(n, p) = V_{e} - E_{c},$$

$$\phi_{h}(n, p) + \mu_{h}(n, p) = V_{h} - E_{v}.$$
(4)

Note that E_c and E_v in these equations refer to the conduction and valence band edges in the absence of carriers and are defined relative to the Fermi level of the gates. The left-hand sides of these equations are functions of n and p with ϕ_e and ϕ_h given by the electrostatic equations (2), and μ_e and μ_h determined by the many-body physics of the electron-hole fluid. In Eq. (4) μ_e and μ_h are defined as the electrochemical potentials of the electron and hole layers relative to their local band extrema. Experiments which measure n and pas a function of V_e and V_h therefore provide a valuable thermodynamic probe of electron-hole fluid properties. In the following section we discuss mean-field theory estimates for $\mu_e(n, p)$ and $\mu_h(n, p)$ that provide valuable insight into expected properties. In general Eqs. (4) define two lines in (n, p) space that intersect at the equilibrium carrier densities. As we discuss below, however, singularities along the n = pline associated with the formation of excitonic bound states require special considerations.

III. MEAN-FIELD THEORY OF THE UNBALANCED ELECTRON-HOLE FLUID

We consider a bilayer electron-hole system with electron and hole densities n and p, neutralizing backgrounds in both electron and hole layers, and the band extrema energies of both the conduction band and the valence band set to zero. With these conventions, the electron and hole chemical potentials of the interacting electron-hole system correspond to the chemical potentials $\mu_e(n, p)$ and $\mu_h(n, p)$ in Eqs. (4). The mean-field Hartree-Fock Hamiltonian of the electronhole system is

$$H_{\rm MF} = H_{\rm eh} + H_X,\tag{5}$$

where $H_{\rm eh}$ is the two-band single-particle Hamiltonian for electrons and holes

$$H_{\rm eh} = \sum_{k} \left(\frac{\hbar^2 k^2}{2m_e^*} a_{ck}^{\dagger} a_{ck} - \frac{\hbar^2 k^2}{2m_h^*} a_{vk}^{\dagger} a_{vk} \right), \tag{6}$$

where *c* and *v* stand for the conduction band of the electron layer and the valence band of the hole layer. As explained above, the zero of energy for the electron layer is chosen at the bottom of the conduction band, and for the hole layer at the top of the valence band. Because of the assumption of neutralizing backgrounds there is no electrostatic mean-field potential, and H_X is the exchange self-energy [20–22]:

$$H_X = -\frac{1}{A} \sum_{kk'} V_{b'b}(k'-k) \rho_{b'b}(k') a^{\dagger}_{b'k} a_{bk}, \qquad (7)$$

where *A* is the area of the two-dimensional system, b = c, v is the band index, $V_{cc}(q) = V_{vv}(q) = V(q) = 2\pi e^2/\epsilon q$ is the intralayer Coulomb interaction, $V_{cv}(q) = V_{vc}(q) = U(q) = V(q) \exp(-qd)$ is the interlayer Coulomb interaction at interlayer distance *d*, and ϵ is the dielectric constant of the surrounding three-dimensional material. In Eq. (7) ρ is the density matrix calculated relative to the density matrix when the conduction band is empty and the valence band is full:

$$\rho_{b'b}(\boldsymbol{k}) = \langle a_{b\boldsymbol{k}}^{\dagger} a_{b'\boldsymbol{k}} \rangle - \delta_{b'b} \delta_{bv}. \tag{8}$$

Below we express lengths and energies in terms of characteristic scales $a_B^* = \epsilon \hbar^2 / m^* e^2$ and $Ry^* = e^2 / 2\epsilon a_B^*$, where $m^* = m_e^* m_h^* / (m_e^* + m_h^*)$ is the reduced effective mass. For simplicity we perform numerical calculations only for the $m_e^* = m_h^* = 2m^*$ case. This model approximates MoSe₂/WSe₂ bilayers surrounded by hexagonal boron nitride (hBN) dielectrics if we choose $m^* \approx 0.2 m_e$, and $\epsilon \approx 5$, which implies that $a_B^* \approx 1.3$ nm and $Ry^* \approx 0.11$ eV. The calculations below are for the case $d = a_B^*$, corresponding approximately to the case with one or two hBN layers between the MoSe₂ and WSe₂ monolayers [23].

In order to provide an interpretation for the mean-field theory results presented below, we first discuss a simple phenomenological picture in which we assume that the electronhole fluid consists of paired (excitons) and unpaired electrons or holes. If we assume that the physically preferred state of the system is one with the maximum number of electronhole pairs, then the system consists of $n_x = \min(n, p)$ excitons and |n - p| unpaired electrons or holes. In this picture the total energy per area of the system at small n and p can be approximated by the simple expression

$$\varepsilon(n,p) = -\varepsilon_b n_x + \frac{g}{2} n_x^2 + \frac{\alpha}{2} (n-p)^2, \qquad (9)$$

where ε_b is the exciton binding energy, g describes excitonexciton interactions, and α is the inverse thermodynamic



FIG. 1. Electrically controlled electron-hole fluids. We consider a dual gated geometry with both gates held at the same voltage. The electron and hole layers are contacted by electrodes with voltages $-V_e$ and $+V_h$, respectively, relative to the gate.

density-of-states of the unpaired electrons or holes. This expression implies that the total energy $\varepsilon(n, p)$ has a cusp at n = p. The chemical potentials in which we are primarily interested are given by

$$\mu_e(n, p) = \frac{\partial \varepsilon(n, p)}{\partial n},$$

$$\mu_h(n, p) = \frac{\partial \varepsilon(n, p)}{\partial p}.$$
(10)

For n < p adding an electron adds an exciton and removes a free carrier, whereas for n > p adding an electron simply adds a free carrier. In a similar way, adding a hole simply adds a free carrier for n < p, whereas for n > p it adds an exciton and removes a free carrier. For this reason the chemical potentials of electrons and holes jump in opposite directions by ε_b when the n = p line is crossed. The chemical potential for excitons

$$\mu_x = \mu_e + \mu_h \tag{11}$$

is however continuous. For $n = p = n_x$ our *ansatz* energy expression, Eq. (9), places all electrons and holes into pairs and the exciton chemical potential

$$\mu_x(n_x) = -\varepsilon_b + gn_x. \tag{12}$$

We now compare this simple physical picture with microscopic mean-field theory calculations performed as a function of *n* and *p*. First of all, in Fig. 2(a) we plot the exciton chemical potential at n = p calculated as a function of n_x and compare it with Eq. (12). By linearly fitting the small-*n* part of the curve we find that the exciton binding energy $\varepsilon_b = 0.77 Ry^*$ and the exciton-exciton interaction parameter $g = -12 (Ry^* a_B^{*2})$. The negative value of *g* here implies that the interaction between interlayer excitons would be attractive at the considered interlayer separation $d = a_B^*$ if electrostatic interactions, which are suppressed at this stage because of the neutralizing backgrounds in each layer in the reference system calculation, were ignored. Technically this property reflects the dominance of intralayer Coulomb interactions, and agrees with previous studies [20]. At large exciton density $(n_x a_B^{*2} \gtrsim 0.02)$ higher-order interaction of Eq. (12), and the simple expression (9) is no longer a good approximation.

According to Eq. (9)

$$\mu_e = \alpha(n-p) - (\varepsilon_b - gn)\Theta(p-n), \tag{13}$$

where $\Theta(x)$ is the Heaviside step function. The electron chemical potential calculated from microscopic mean-field theory is plotted as a function of *n* for fixed *p* in Fig. 2(b). The upward jump in the electron chemical potential anticipated in the ansatz expressions is prominent. The parameter α , the quasiparticle inverse thermodynamic density of states, accounts for the rate of change of electron chemical potential near the n =*p* point. A linear fit gives $\alpha = -115 (Ry^*a_B^{*2})$. This negative value of α is related to the negative compressibility property, which applies also in single-component systems, and is due to the dominance of exchange interactions in low-density electron gases [24–26]. The size of the chemical potential jump at n = p is plotted vs carrier density in Fig. 2(c). The ansatz expression for this quantity is

$$\Delta \mu(n_x) = \varepsilon_b - gn_x = -\mu_x. \tag{14}$$

However, comparison of Figs. 2(a) and 2(c) shows that the behavior of $-\mu_x$ and $\Delta\mu$ are very different when *n* is not small. Fitting these two quantities at the small-*n* part yields different slopes but almost identical $n \rightarrow 0$ intercepts. This implies that while the physical picture represented by Eq. (9) is oversimplified, it does capture a large part of the truth.

The chemical potentials calculated in this section are based on a temperature T = 0 mean-field theory, which yields an electron-hole pair condensate ground state. Although this theory is expected to become exact at T = 0 in the limit of very low carrier densities, it is expected to fail at large carrier densities. It is generally thought that [27–29] at high enough



FIG. 2. Chemical potentials as functions of carrier densities from mean-field calculations: (a) exciton chemical potential μ_x vs carrier density n(=p); (b) chemical potential of electrons μ_e vs electron density n at fixed p; and (c) chemical potential jump $\Delta \mu$ at neutrality vs carrier density n(=p).

carrier density a Mott limit is reached above which exciton condensation does not occur. Although we use these chemical potentials in the following section to discuss some qualitative expectations, an equally important aspect of our analysis is that it can be used in combination with experimental measurements of the dependence of carrier densities on gate voltages to extract chemical potential data from experimental observations. Experiments of this type would be especially valuable at higher temperatures where mean-field theory is not expected to be reliable.

IV. GATE CONTROL OF CARRIER DENSITIES

The left-hand sides of Eqs. (4) are functions of n and p. For given values of *n* and *p*, ϕ_e and ϕ_h are given by the electrostatic equations (2), while μ_e and μ_h are more complex quantities that depend on correlations in the electron-hole fluid. For given gate voltages V_e and V_h , Eqs. (4) can have one or more solutions, the latter instance would signal bistability or multistability of the electron-hole system. In Fig. 3 we plot $\phi_{e/h} + \mu_{e/h}$, calculated using mean-field theory chemical potentials, as functions of total carrier density (n + p)/2 and total charge density (n - p)/2. One important feature of this plot is the jump in electrochemical potentials across the n =p line discussed above. Aside from the jump at neutrality, increasing net charge density changes the electrochemical potentials rapidly mainly because of the electrostatic contributions. ϕ_e increases with n - p, ϕ_h decreases with n - p, and both changes are rapid because of the relatively large distance to the gates. (Note the difference in scales for the x and y axes in Fig. 3.) At fixed n - p, both electrochemical potentials increase with n + p, mainly because of band filling.



FIG. 3. Color plot of $\phi_e + \mu_e$ (upper panel) and $\phi_h + \mu_h$ (lower panel) as functions of (n + p)/2 and (n - p)/2. The black dotted lines are contour lines along which $\phi_{e/h} + \mu_{e/h} = 0.8Ry^*$. For the calculation of ϕ_e and ϕ_h we assume $d_e = d_h = 20a_B^*$ and $d_s = a_B^*$.



FIG. 4. Color plot of (n - p)/2 as a function of $V_e - E_c$ and $V_h - E_v$. The black dotted lines are the boundaries of the n = p region.

From Eqs. (4) we see that the equilibrium values of *n* and *p* for given values of the control gate voltages V_e and V_h correspond to the intersections of the contour lines in Fig. 3 along which $\phi_e(n, p) + \mu_e(n, p) = V_e - E_c$ and $\phi_h(n, p) + \mu_h(n, p) = V_h - E_v$. Since the contour lines of $\phi_e + \mu_e$ have negative slopes when plotted with n + p along the *x* axis and n - p along the *y* axis (as in Fig. 3) while those for $\phi_h + \mu_h$ have positive slopes, the lines never intersect more than once. We conclude the bistability is unlikely when the electron and hole layers are separated by an hBN tunneling barrier and the gates are well separated from the active layers.

Special care must be taken along the n = p line where the electron and hole electrochemical potentials jump, yielding the horizontal portions of the contour lines in Fig. 3. The electron and hole chemical potentials are ill defined along these horizontal line segments because it is not energetically allowed to exchange particles with individual reservoirs. It is however possible to exchange an electron-hole pair with the reservoirs via a two-particle correlated tunneling process [15]. Correlated electron-hole tunneling is relevant when the difference between $V_e - E_c$ and $V_h - E_v$ is smaller than the chemical potential jump at neutrality, so that the horizontal segments of two contour lines in Fig. 3 intersect. Under this circumstance the exciton chemical potential is still well defined, and its value at $n = p = n_x$ is determined by solving the pair equilibrium condition

$$\phi_e + \mu_e + \phi_h + \mu_h = V_e - E_c + V_h - E_v.$$
(15)

This implies a finite region (rather than a line) in the (V_e, V_h) parameter space in which n = p as illustrated in Fig. 4. The width of this region first increases with increasing gate voltages and then narrows. Defining the right-hand side of Eq. (15) as the bias voltage V_b we obtain the results for the exciton density as a function of V_b shown in Fig. 5. The system is supplied with excitons when $V_b > -\varepsilon_b$. Above the bias voltage threshold the curve is initially linear because of exciton-exciton interactions. The sum of electron and hole densities varies smoothly with gate voltage in the entire (V_e, V_h) plane as illustrated in Fig. 6.



FIG. 5. Exciton density $n = p = n_x$ as a function of bias voltage V_b when (V_e, V_h) is in the neutral region.

V. LEAKAGE CURRENTS

The theory in the previous sections applies when there is no current flowing between layers. In the presence of a tunneling current, the theory still applies as a good approximation if the current is small enough so that we can assume quasiequilibrium in each layer. In the following we discuss the opposite limit, in which a large leakage current between layers requires a nonequilibrium transport picture. By analyzing this limit we are able to qualitatively explain the transport characteristics observed in a recent experimental study of electrically controlled electron-hole bilayers [1].

For definiteness we consider $MoSe_2/WSe_2$ bilayer systems in which the $MoSe_2$ layer is *n* type and the WSe_2 is *p* type. In a typical experimental setup, the two layers do not perfectly overlap, leaving isolated monolayer regions between the bilayer region and the electrical contacts. We sketch an idealized geometry in Fig. 7 in which we divide the system into three parts: Regions I and III are isolated WSe_2 and $MoSe_2$ monolayer regions, while region II is the overlapped bilayer region. Assuming that V_h is above threshold, region I is filled with holes with density $p_1 \propto V_h - E_v$. Imagine we now



FIG. 6. Color plot of (n + p)/2 as a function of $V_e - E_c$ and $V_h - E_v$. The black dotted lines are the boundaries of the n = p region. The total carrier density is a smooth function of the voltage control parameters.



FIG. 7. Schematic of electron-hole transport processes in a bilayer system with isolated monolayer regions near the contacts and effective contact resistances that are larger than the effective interlayer resistances. The thick black lines show the geometry of the bilayer system and the top and bottom gates. The local bands of MoSe₂ and WSe₂ are shown in blue and green, respectively, and the dotted lines show the Fermi levels of the electron and hole bands set by the gate and bias voltages. In this schematic the tunneling current is limited by the injection current from region III, and regions II and III in the MoSe₂ layer are not able to reach equilibrium.

increase V_e from a small value. When V_e is below threshold, there are no free carriers in the MoSe₂ layer, so no current flows and the electric field distribution is not affected by the MoSe₂ layer. The whole WSe₂ layer is uniformly charged and in equilibrium with the left lead. The electric potential on the MoSe₂ layer in region II is very close to that of the WSe₂ layer due to the small interlayer distance, while in region III the electric potential is the same as the gates since the whole layer is neutral. The electric potential jump between regions II and III implies a sharp bending of the MoSe₂ bands at the boundary.

When V_e increases above threshold, region III starts to get charged toward electron density $n_{\rm III} \propto V_e - E_c$. Due to the electric potential jump, current is injected into empty states in region II and tries to fill the band to the same level as in region III. The injection current $I_{e,inj}$ is a function of n_{III} (and therefore depends on $V_e - E_c$ only). Importantly it does not depend on the physics in regions I and II (as long as region II is far from equilibrium with III). Were it not for the leakage current between the two layers in region II, the whole MoSe₂ layer would finally come to equilibrium with the right lead, and the theory in the previous sections would apply. However, as we schematically show in Fig. 7, a large leakage current can prevent the system from establishing equilibrium. The leakage current I_{leak} is a monotonically increasing function of the carrier densities $n_{\rm II}$ and $p_{\rm II}$. If $n_{\rm II}$ and $p_{\rm II}$ reach value such that $I_{\text{leak}} = I_{\text{e,inj}}$ before equilibrium is established, the system will reach a nonequilibrium current-carrying steady state. The current through the system is limited by the injection current from region III, which depends only on $V_e - E_c$. Meanwhile, the WSe₂ layer in regions I and II maintains equilibrium with the left lead.

Similar considerations apply to region I, which like region III also has a maximum injection current $I_{h,inj}$ that is a function of $p_{I} \propto V_{h} - E_{v}$. When V_{e} is so large that $I_{e,inj} > I_{h,inj}$, the tunneling current is limited by the injection current from region I, while regions II and III stay in equilibrium with

the right lead. The transition takes place when $I_{e,inj}(n_{III}) = I_{h,inj}(p_I)$. Since $I_{e,inj}(n_{III})$ and $I_{h,inj}(p_I)$ are similar functions of carrier density, roughly speaking this happens when $n_{III} = p_I$, or $V_e - E_c = V_h - E_v$. The most important conclusion from this analysis above is that, as long as the system is in the *p*-*n* regime, the tunneling current is determined by the following equation:

$$I(V_e, V_h) = \min\{I_{e,\text{inj}}(V_e), I_{h,\text{inj}}(V_h)\}.$$
 (16)

The leakage current consists of three parts (see Fig. 7): Electron tunneling I_e , hole tunneling I_h , and interband electron-hole phonon-assisted tunneling or optical recombination I_{eh} . Due to the relatively weak electroluminescence observed in experiments, we assume that $I_{eh} \ll I_e$, I_h . Then the tunneling current has a threshold when the chemical potential in the electron layer is above the bottom of the conduction band in the hole layer (or when the chemical potential in the hole layer is below the top of the valence band in the electron layer). Above threshold the tunneling conductance far exceeds the corresponding injection current conductance from monolayer regions at the same chemical potential. In this case the total current is limited by injection from monolayer regions as discussed above, and the details of the interlayer tunneling process do not matter. One possible way to study interlayer tunneling is to tune the chemical potential below threshold, so that the tunneling current only has a single weak component I_{eh} . This can be made easier by applying a vertical electric field between the two layers to tune the indirect band gap. The dependence of I_{eh} on carrier densities n, p can provide clues that help us understand the correlated electron-hole states and possibly provide evidence for exciton condensation.

We now provide a crude estimate of the injection current by considering the ballistic transport limit. Consider an electron with momentum $(k \cos \theta, k \sin \theta)$ moving across a rectangular region with length *L* and width *W*, with $\theta = 0$ along the length direction. The electron passes through the region in time $m_e^*L/\hbar k \cos \theta$, and therefore provides the current contribution

$$i(k,\theta) = \frac{e\hbar k\cos\theta}{m_e^* L}.$$
(17)

Assuming that all electrons with $k_x > 0$ contribute to the current, we integrate over half of the Fermi sea (accounting for valley degeneracy) to obtain

$$I = 2 \int_{-\pi/2}^{\pi/2} d\theta \int_{0}^{k_{F}} \frac{kdk}{(2\pi)^{2}/LW} i(k,\theta) = \frac{e\hbar W k_{F}^{3}}{3\pi^{2} m_{e}^{*}}.$$
 (18)

Here the Fermi momentum is related to the carrier density by

$$\frac{\pi}{2}k_F^2 = nWL\frac{(2\pi)^2}{2WL} = 2\pi^2 n \implies k_F^2 = 4\pi n.$$
(19)

For the monolayer region, it is a good approximation to assume $\phi = V_e - E_c$ when $V_e > E_c$ because of its large distance from the gates. By simple electrostatics the carrier density is given by

$$\frac{4\pi ne^2}{\epsilon} = \phi \left(\frac{1}{d_e} + \frac{1}{d_h}\right). \tag{20}$$

For $\phi = 1$ eV, $d_e = d_h = 25$ nm, and $\epsilon = 5$, we obtain $n = 2.21 \times 10^{12} cm^{-2}$. Then for $W = 3 \ \mu m$ and $m_e^* = 0.4 \ m_e$, from Eq. (18) we estimate the current

$$I = 687 \ \mu \text{A},$$
 (21)

which is, as expected, much larger than the current observed in experiment due to the unrealistic assumption of perfect transmission. The ballistic transport picture gives $I \propto (V_e - E_c)^{3/2}$, in contrast to the $I \propto (V_e - E_c)^3$ relation found in experiment. The difference can be explained by the fact that electron transmission is not perfect and depends on energy. We can make our result agree with the experiment by introducing a phenomenological energy-dependent transmission probability $T(E) \propto E^{3/2}$ where E is the electron energy relative to conduction band bottom. With a similar analysis for holes, we restore the cubic law found in experiment [1]:

$$I(V_e, V_h) \propto \min\{V_e - E_c, V_h - E_v\}^3.$$
 (22)

VI. DISCUSSION

In this article we have analyzed how two gate voltages V_e and V_h can be used to control the electron and hole densities n and p, and hence all properties, of bilayer two-dimensional electron-hole fluids. When there is no leakage current between electron and hole layers contacted by electrodes with different chemical potentials, bias voltages can be used to tune the bilayer into an effective semimetal regime in which carriers are present in both n and p layers. Because of jumps in electron and hole chemical potentials related to electron-hole pair bound state formation, which occur along the n = pcarrier-compensation line, there is a finite area in the (V_e, V_h) gate-control region, instead of a line, within which n = p. In this region the electron and hole chemical potentials are not individually well defined. Instead their sum, identified as the exciton chemical potential, is well defined and controlled by the value of $V_e + V_h$. Figure 4 outlines the boundaries of the excitonic area in the control space as estimated by mean-field theory. We anticipate that the width of this region, which is a measure of the chemical potential jumps at neutralityreferred to as the exciton binding energy below-narrows with increasing exciton density due to dynamic screening of the electron and hole interactions [27–29], exciton-exciton attractive van der Waals interactions [30], and other effects that are not captured by mean-field theory. Although the fate of this quantity, which has not previously been experimentally accessible, is usually not explicitly discussed in the literature, the most common view appears to be that the exciton binding energy drops suddenly to zero at a first-order Mott transition. Another view is that the exciton binding energy declines monotonically with increasing density in a crossover between BEC and BCS limits, but never vanishes. Still another possibility is that the exciton binding energy vanishes smoothly at a continuous phase transition. Capacitive studies of electron-hole bilayers should be able to provide a definitive experimental answer to this question.

Within the finite-area exciton region of the gate control space $V_e + V_h$ acts as a chemical potential for excitons. By using contact pairs to establish exciton reservoirs with different chemical potentials at different locations in a bilayer system,

we anticipate that it will be possible to measure electrical and thermal transport properties of excitons, and to design exciton circuits. This exciting prospect is a principle motivation for formulating the analysis presented in this article.

We have compared our analysis with a recent experimental paper [1] that reports on important progress toward electrical control of electron-hole bilayers, and therefore of the their optical and transport properties. We conclude that the transport properties reported in Ref. [1] are indicative of electron-hole systems that are not in a quasiequilibrium configuration, but instead in a transport steady state that is strongly influenced by the intraband leakage current between the bilayers. The leakage current is easily reduced, however, by inserting dielectric layers between the 2D semiconductors, or simply by reducing the area of overlap between the two 2D semiconductor layers. We can anticipate that further progress will enable accurate control of quasiequilibrium electron-hole bilayers, and by staying within the n = p region, electrical and thermal control of exciton currents.

The relationship between electron and hole densities and gate voltages depends on both many-body correlations and disorder within the 2D semiconductor layers. In this paper we have ignored disorder and used a mean-field theory to describe interactions in the electron-hole system. The mean-field theory is expected to be accurate when n = p at low electron and hole densities, but it is precisely in this regime that disorder is most important. For small $n \neq p$, weak disorder, and small layer separations we expect that additional new physics will appear. In particular, it is clear from optical studies [31–37] of spatially direct electron-hole systems that there is an accessible regime in which the carriers organize into excitons, trions, and free particles. Trion bound states

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survive in spatially indirect systems out to substantial layer separations [38,39] and have been identified experimentally [40]. When trion bound states are present the phenomenological expression for the electron-hole fluid energy density that accounts only for excitons, Eq. (9), should be generalized to

$$\varepsilon(n, p) = -\varepsilon_{xb}n_x - (\varepsilon_{xb} + \varepsilon_{tb})n_t + \frac{g_{xx}}{2}n_x^2 + \frac{g_{tt}}{2}n_t^2 + g_{xt}n_xn_t + \frac{\alpha}{2}n_u^2, \qquad (23)$$

where $n_t = \min(n, p, |n - p|)$ is the density of trions, $n_x =$ $\min(n, p) - n_t$ is the density of excitons, $n_u = |n - p| - n_t$ is the density of unpaired electrons or holes, ε_{xb} is the exciton binding energy, ε_{tb} is the trion binding energy, and g_{xx} , g_{tt} , and g_{xt} are the coefficients of exciton-exciton, trion-trion, and exciton-trion interactions. It follows from this expression that the chemical potentials have jumps at n = 2p and at n = p/2 in addition to those at n = p on which we have focused. For example, at n = 2p (and n, p both small) the chemical potential of electrons μ_e jumps by ε_{tb} . If samples with sufficiently weak disorder can be fabricated, electrical control should make it possible to identify trion binding in the electron-hole fluid optically or capacitively, and to explore the richness of the electron-hole fluid that flows from attractive electron-hole interactions to be studied in unprecedented detail.

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